

High wall plug efficiency THz QCLs: investigation of the optical, electronic and thermal performance

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Outline

- ❖ THz Quantum Cascade Lasers (basic concepts and state of art)
- ❖ Demonstration of high power and high wall plug efficiency THz QCLs
- ❖ Real-time μ -probe photoluminescence \rightarrow
 - Thermal self-calibrated approach to measure the wall-plug efficiency of QCLs
 - Local lattice temperature (facet + top)
 - Electronic temperature and electron-lattice coupling
 - Dominant role of nm-size abrupt interfaces – TBR
 - Time resolved thermal measurements
- ❖ μ -probe Raman spectroscopy \rightarrow
 - **Non-equilibrium** phonon population

THz QCLs-State of art

Crucial points in the THz range:

- Laser emission at $E < E_{LO}$
- Huge free-carrier absorption ($\sim \lambda^2$)
- Non-radiative lifetimes of intersubband transitions very short

Pisa / (Cavendish)
Neuchâtel / (Neuchâtel)
MIT / Sandia
Teraview / Cavendish
TU Vienna / (Bell Labs)
NRC - Ottawa
Paris 7 / Thales

Bari / Commercial

Quantum designs

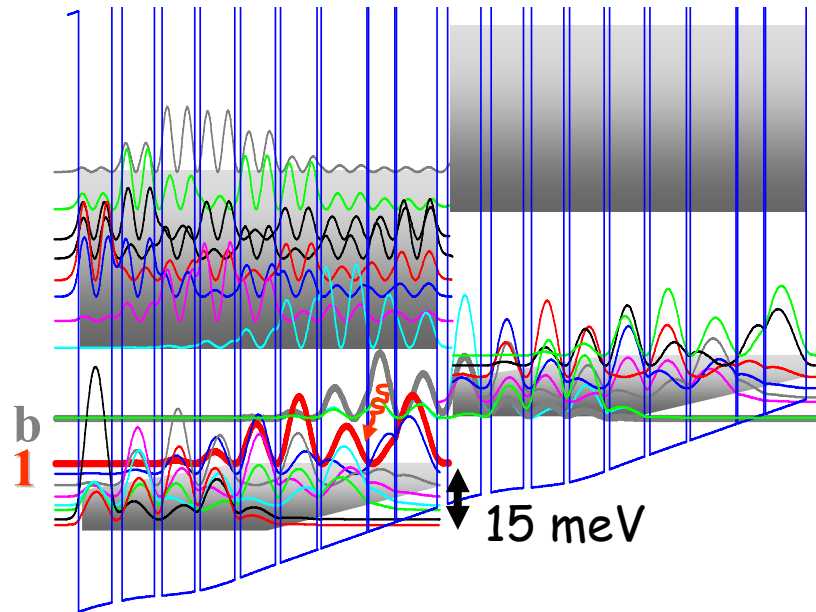
- Chirped superlattices
- Bound-to-continuum
- LO-phonon coupled QW
- Interlaced

State of art - Performance

- $T_{max} = 164K$ (pulsed) 117K (CW)
- $\nu = 1.2$ THz
- $P_o = 245$ mW @ T=4K
- $\eta_{w(max)} \leq 2\%$

Challenges: Increase the maximum CW operating temperature, the optical power out, the wall-plug efficiencies

High Power and High Wall-Plug Efficiency THz QCLs



- Slightly modified version of the bound- to-continuum design (*Barbieri et al. APL 85, 1674 2004*)
- depopulation of the lower radiative state (**1**) via miniband
- upper radiative state (**b**) localized state in the middle of the minigap.
- $E_{b1} = 11.8$ meV

More **diagonal** radiative transition and slightly reduced dipole matrix element $Z_{b1} = 9.2$ nm

- **Reduced non radiative scattering** of the upper state into the miniband
- Reduced coupling from the injector into the lower radiative state → **improved injection efficiency** η_i

Fabrication and Optical Testing

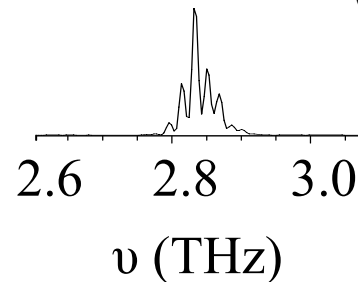
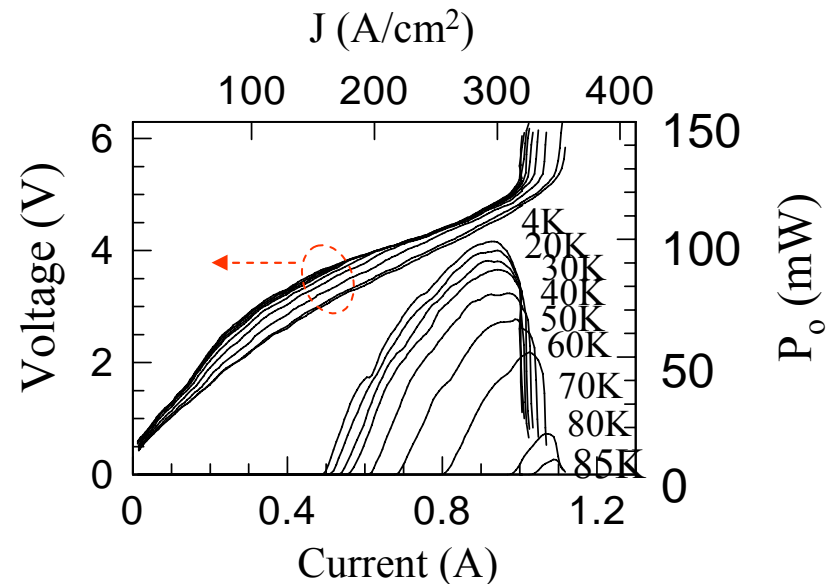
M.S.Vitiello, G.Scamarcio, V.Spagnolo, S.Dhillon and C.Sirtori 90, 191115 (2007)

• MBE growth

- Commercial provider

• Surface-plasmon optical waveguide

- Wet etching
- Ni/Ge/Au/Ni/Au - alloyed bottom contact
- Ge/Au – alloyed metal stripes
- Ni/Au – top not alloyed contact for mode confinement and backside metalization



State of art performance

- High power (~ 100 mW) - a.c.
- Slope efficiency ~ 0.4 W/A ~ 3 times improvement - a.c.
- Record wall-plug efficiency ($\sim 6\%$)
- Differential quantum efficiency: 34 photons for injected electrons at 40 K

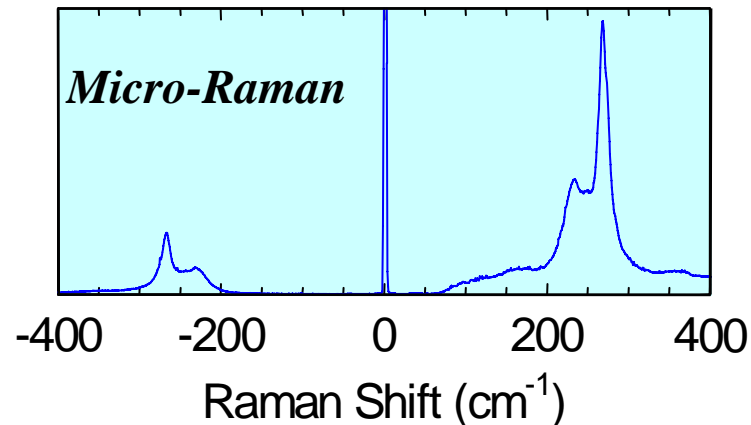
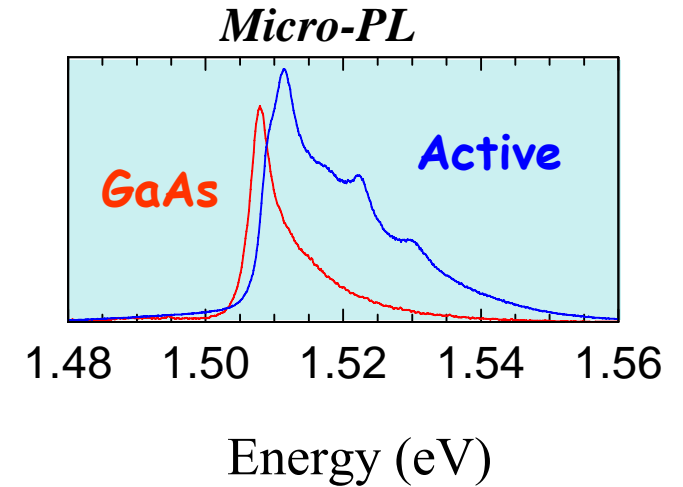
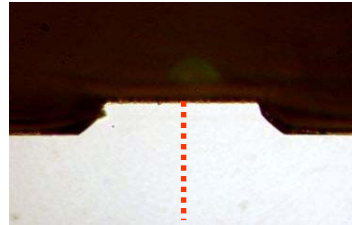
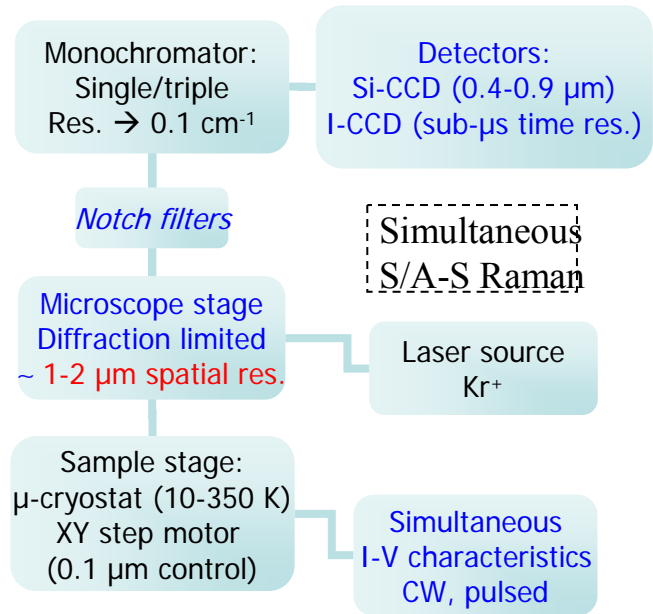
CW performance

$$J_{th} = 215 \text{ A/cm}^2 @ T_{H1} = 20\text{K}$$

$$P_o \sim 24 \text{ mW} @ T_{H1} = 20\text{K}$$

$$\text{Slope efficiency} \sim 0.34 \text{ W/A}$$

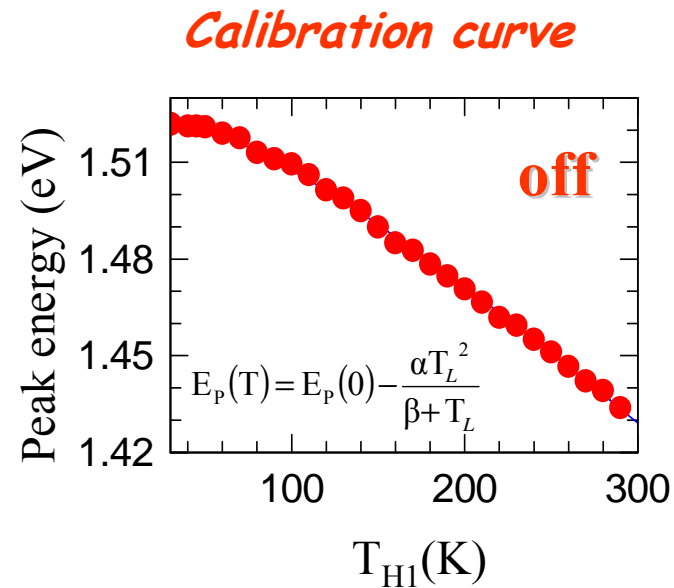
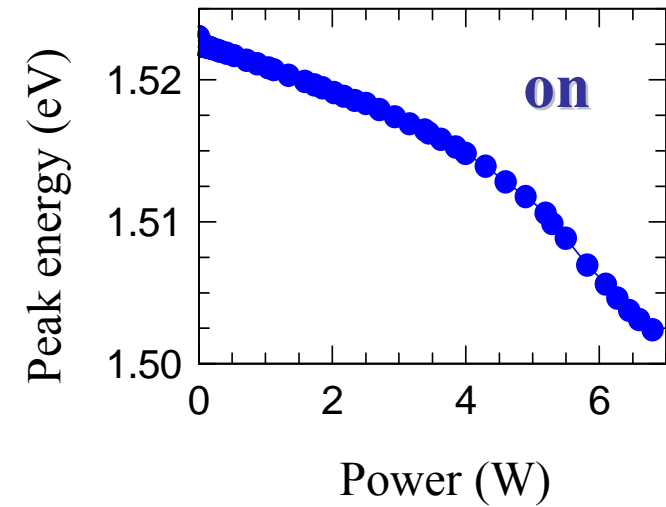
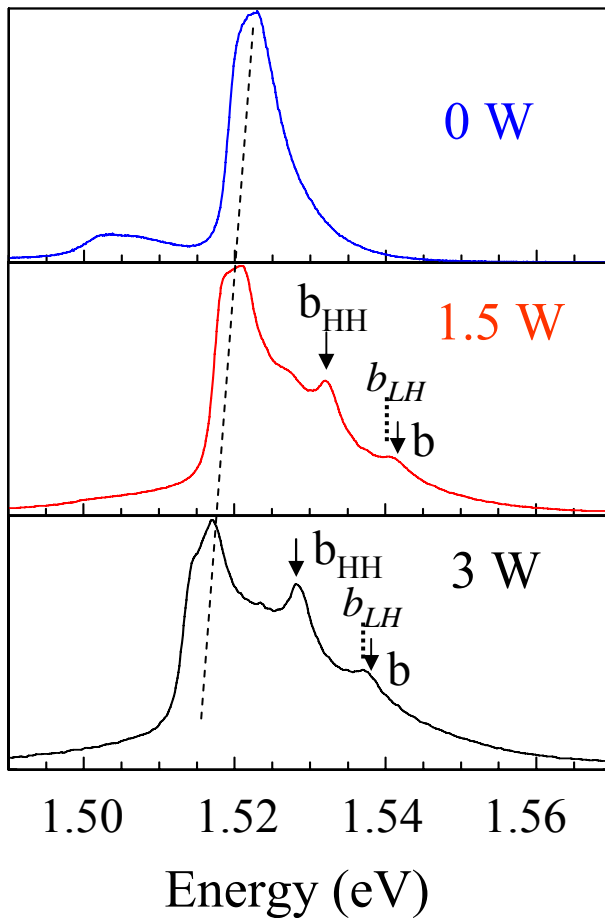
μ -probe spectroscopy on operating QCLs



- Material/layer selectivity
- PL shift / calibration \rightarrow direct thermometric property
- Thermal resistance
- Wall-plug efficiency
- Temperature mapping
- Thermal conductivity
- High-energy slope \rightarrow electronic temperature \rightarrow gain
- Stokes/A-Stokes \rightarrow phonon population

PL spectra - 2.83 THz QCLs

Lattice temperature \rightarrow PL shift



Wall-plug efficiency- Assessment issues

M.S.Vitiello, G.Scamarcio, V.Spagnolo, S.Dhillon and C.Sirtori 90, 191115 (2007)

$$P_{in} = P_{optical} + P_{thermal}; \quad \eta_w = P_{opt}/P$$

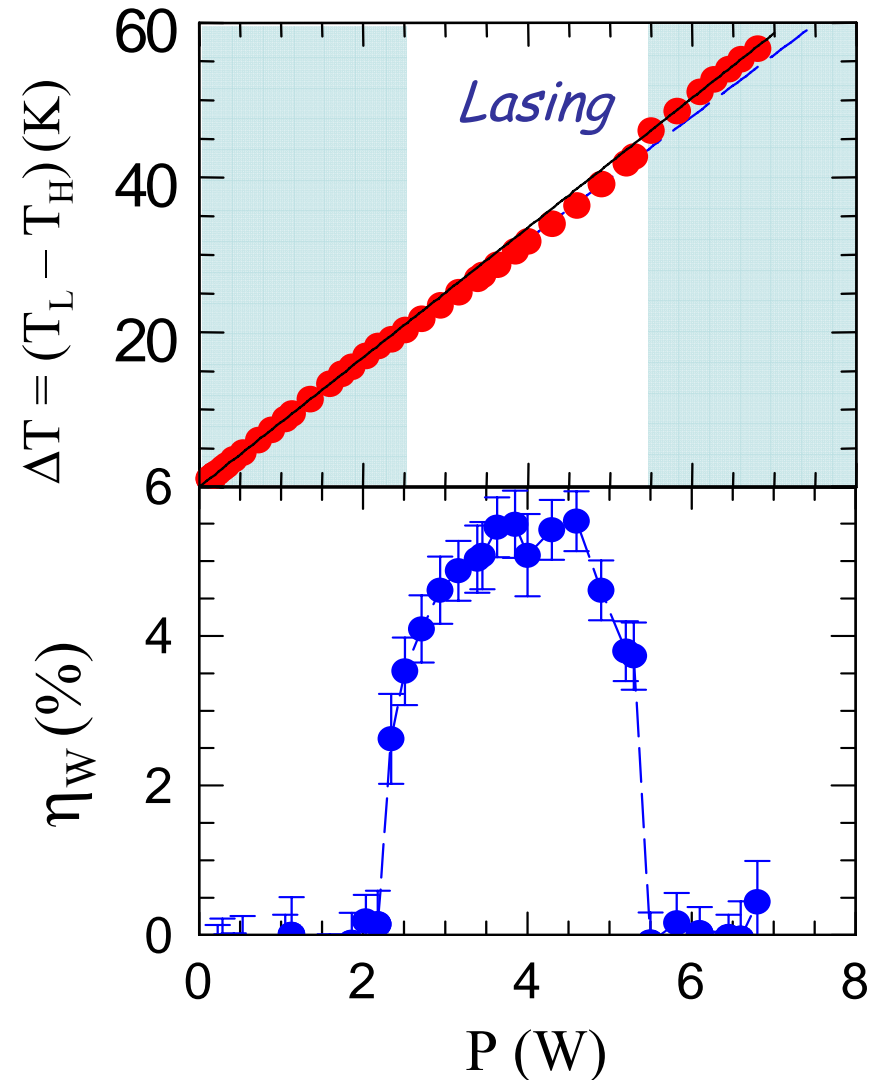
$$\eta_w = 1 - \frac{\Delta T}{P_{in} \times R_L}$$

Thermal resistance

- Conventional optical measurements in THz QCLs affected by
 - Large beam divergence
 - small collection efficiency $\eta_c \sim 0.3$
 - detector calibration

Our self-calibrated approach

- Thermometric properties measured by μ -PL
- Deviations from the thermal resistance trend in the lasing range $\rightarrow P_{thermal} \rightarrow \eta_w$
- $\eta_{wmax} = (5.5 \pm 0.4) \%$



Injection Efficiency

experimental

$$\eta_w = 2 \frac{dP_o}{dI} \frac{I}{V - \Delta V} \left(I - \frac{I_{th}}{I} \right)$$

$$\frac{dP_o}{dI} = \frac{1}{2} N_p \frac{h\nu}{q_o} \frac{\alpha_m}{\alpha_m + \alpha_w} \tau \quad \text{where} \quad \tau = \eta_i \left[1 - \frac{\tau_1}{\tau_2} \left(\frac{1}{\eta_i} - 1 \right) - \frac{\tau_1}{\tau_{21}} \right] \frac{\tau_2}{\tau_1 + \tau_2 [1 - (\tau_1 / \tau_{21})]}$$

From our data $\longrightarrow \frac{\alpha_m}{\alpha_m + \alpha_w} \tau = 0.77 \pm 0.21$

As a rough estimate, assuming: $\left\{ \begin{array}{l} \tau_1 \ll \tau_2, \tau_{12} \text{ as confirmed from the discontinuity} \\ \text{in the differential resistance} \\ \alpha_w \text{ in the range } 2\text{-}6 \text{ cm}^{-1} \\ \alpha_m = 5.85 \text{ cm}^{-1} \end{array} \right.$

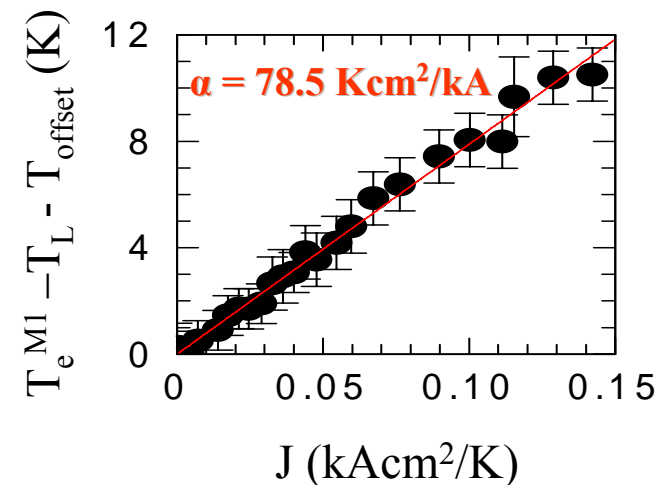
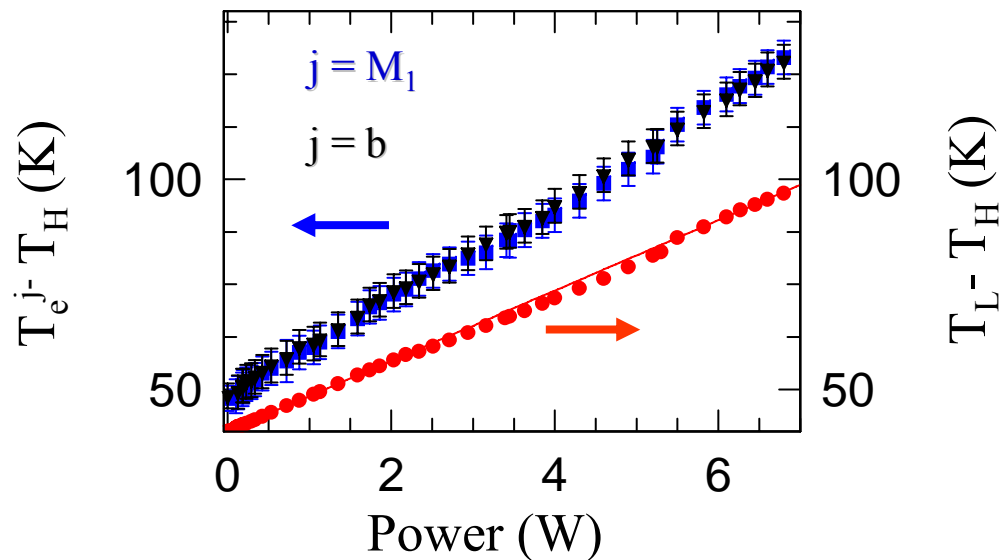
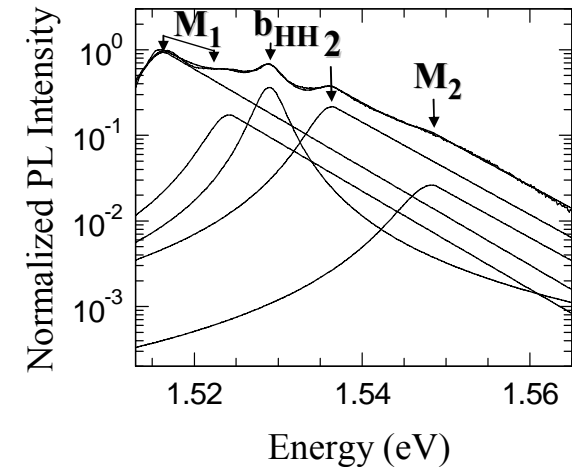
Injection efficiency $\eta_i > 0.75$

- Internal quantum efficiency (LI)
- Gain modeling

Electronic and lattice temperatures -2.83 THz QCLs

M. Vitiello, G. Scamarcio and V. Spagnolo, *J. Nanophoton.*,1, 013514 (2007)

- Lattice temperature \rightarrow PL shift
- **Electronic Temperature** \rightarrow high energy slope analysis
- Features of μ -PL spectra in THz QCLs
 - both ground and excited subbands
 - band-to-band and/or excitonic transitions



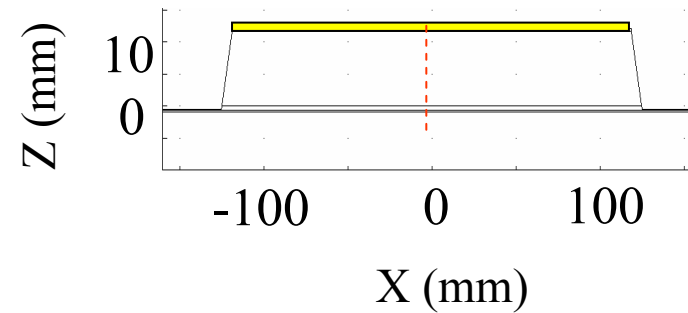
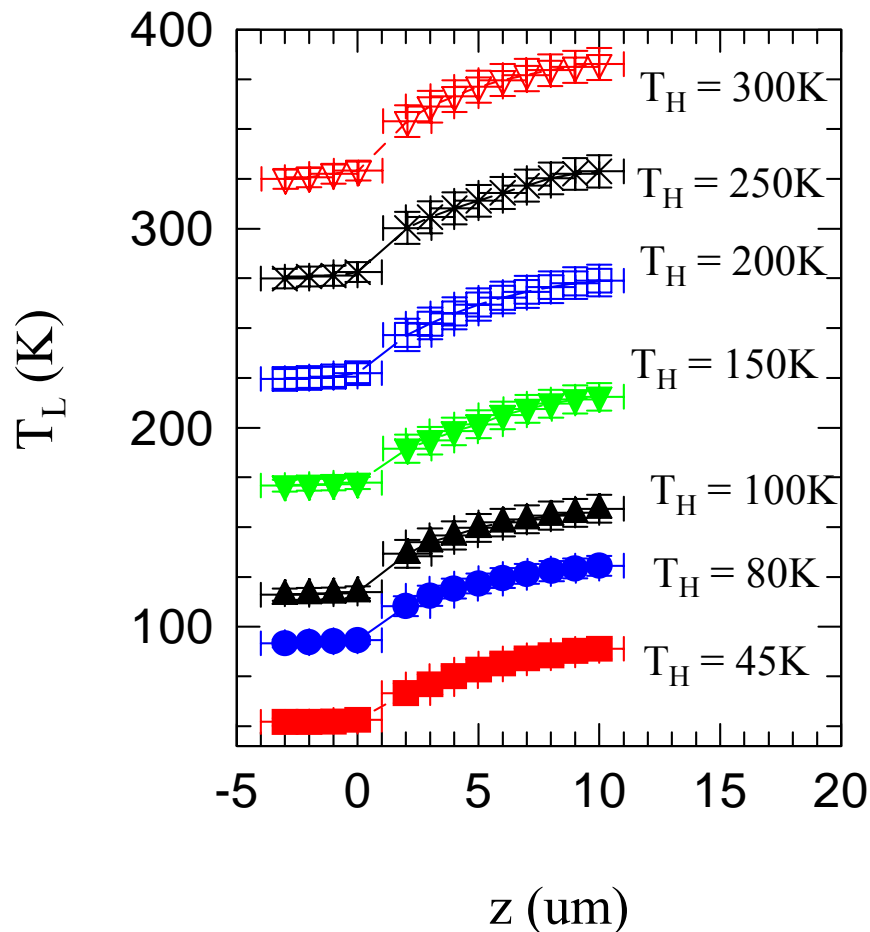
The electrons in the active region share the same T_e

$$R_e = 12.0 \text{ K/W} > R_L = 8.37 \text{ K/W}$$

Most of the electrons dissipate excess energy via slow acoustic phonons assisted transitions

Cross-plane thermal conductivity in THz QCLs

M. Vitiello, G. Scamarcio and V. Spagnolo, submitted to JSTQE (2007)

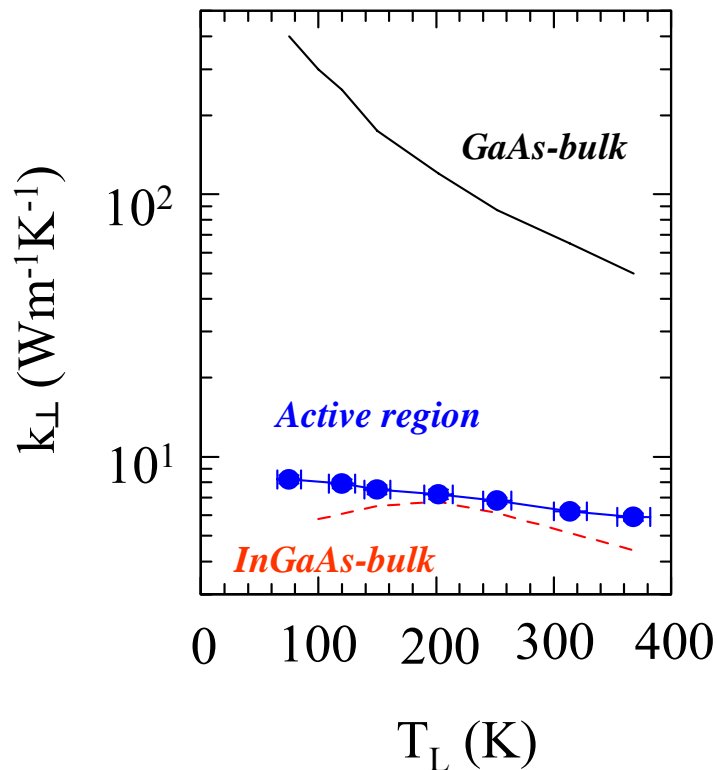


- Lack of lateral heat flow channels $\rightarrow T$ increases *monotonically* in the active
- Heat flux 100% \rightarrow substrate
- k_{\perp} extracted directly from the experimental data, taking advantage from the monotonic trend of the temperature profile and the absence of lateral heat extraction channels



$$k_{\perp} = \left(\frac{T_{\max}(\text{active}) - T(\text{sub})}{P} \times \frac{S}{d} \right)^{-1}$$

Bulk and Interface conductivity in THz QCLs



k_{\perp} decreases monotonically as T is decreased

$k_{\perp} \sim$ one order of magnitude lower than the relevant bulk ones at comparable T

a, b: well, barrier thickness # interfaces

$$k_{\perp}^{-1} = \frac{a}{a+b} R_a + \frac{b}{a+b} R_b + \frac{N}{a+b} TBR$$

Thermal boundary or Kapitza resistance

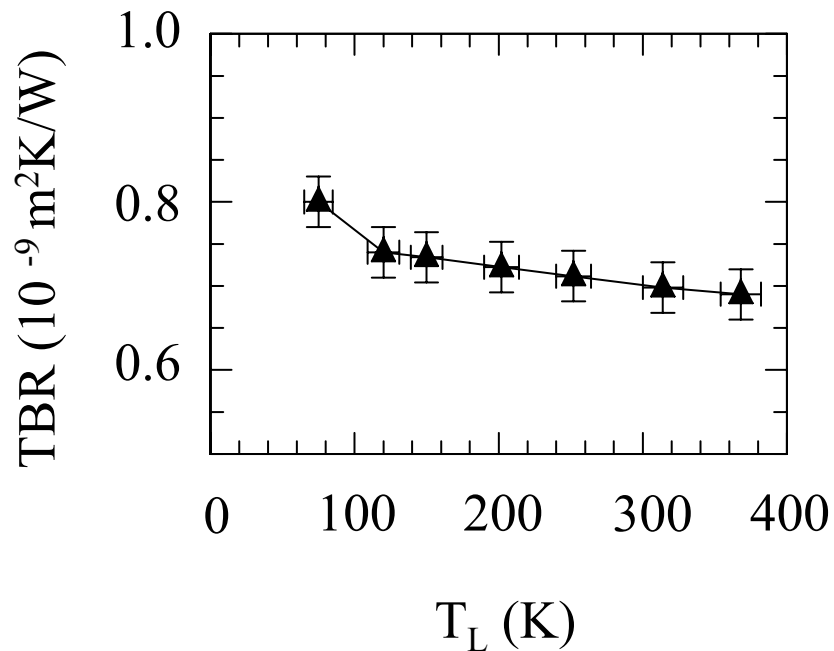
weighed average of bulk resistivities *interface resistivity*

- TBR arises from the mismatch in:
 - Acoustic impedances (mass density x sound velocity)
 - Phonon energy dispersion and densities of states
- If N small \rightarrow interface contribution to R is negligible
- In QCLs:
 - bulk contribution never accounts for the measured values
 - **Interface thermal resistivity dominant**

Thermal boundary resistance

Comparing experimental k_{\perp} with calculated bulk contributions \rightarrow TBR

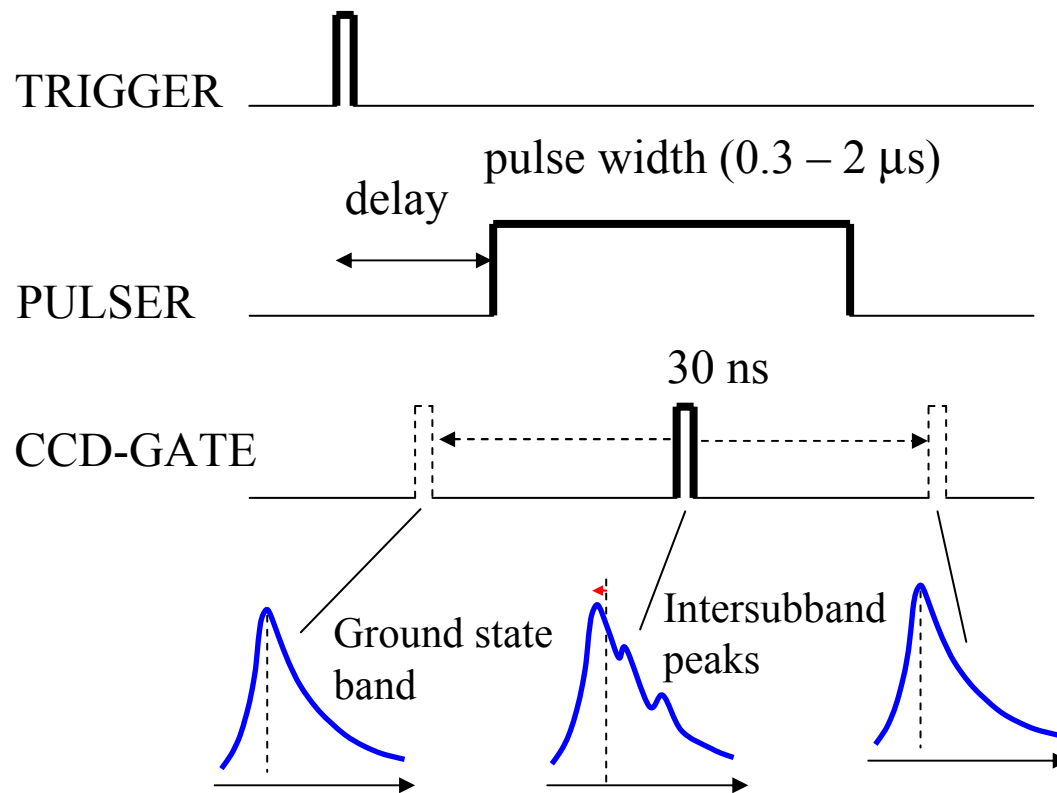
TBR decreases with temperature



Why ?

- low T \rightarrow λ phonon long \rightarrow umklapp scattering frozen out and boundary scattering dominates
- T increases \rightarrow λ phonon decreases and \sim size of the defects \rightarrow defect scattering dominates
- high T \rightarrow λ phonon shorter (larger wavevectors) \rightarrow umklapp scattering dominant

Time resolved μ -PL



ADVANTAGES

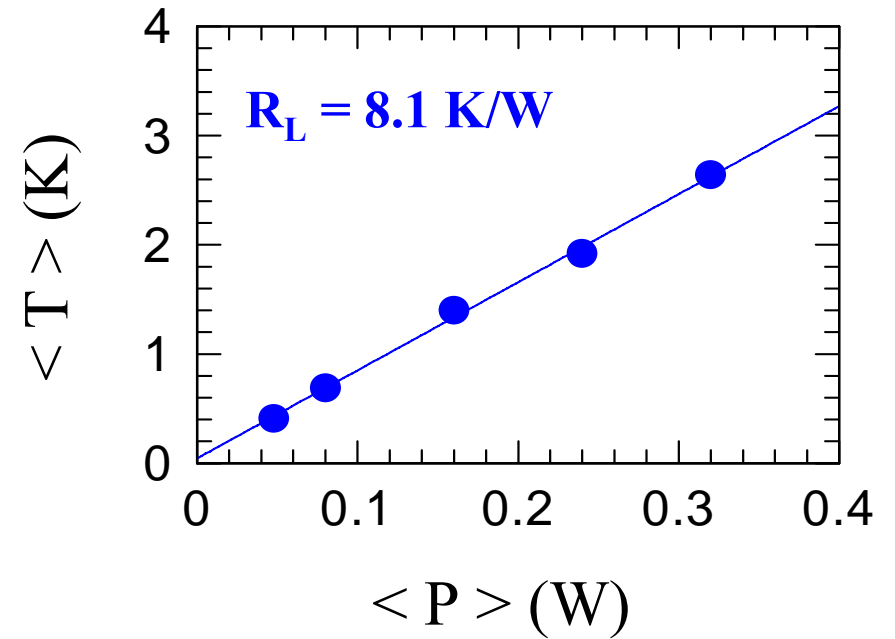
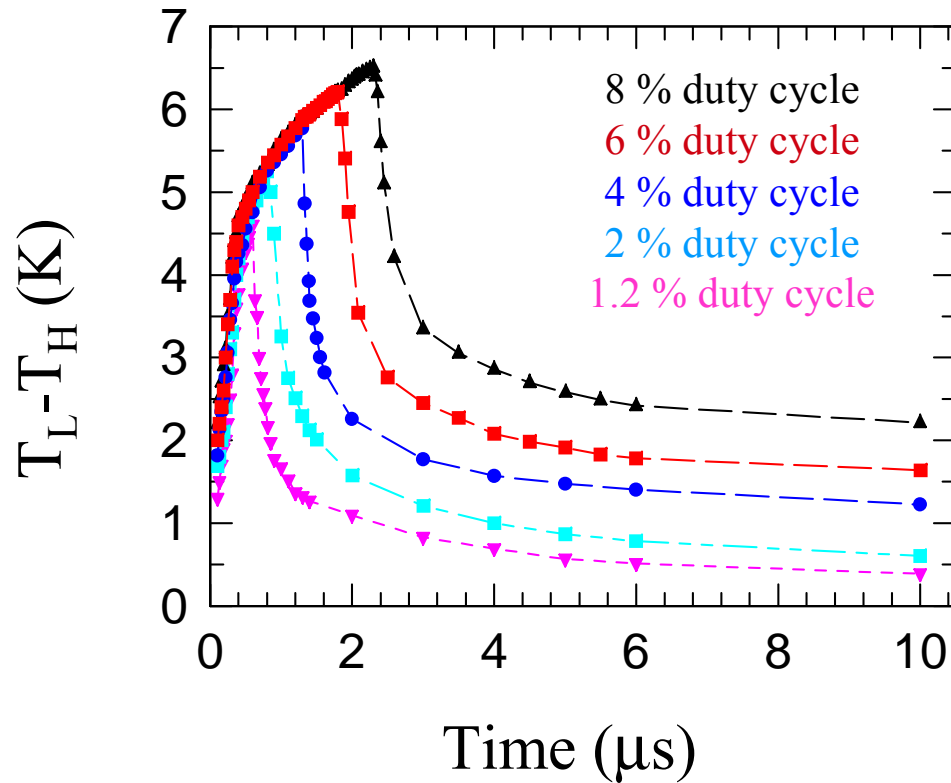
Low mean power dissipated

- Investigation of QCL thermal dynamics under pulsed operation well above laser threshold and roll-off
- QCL dynamics at very high operating temperatures

OUTCOME

Heat diffusion dynamics

Thermal dynamics under pulsed operation @ T = 80K

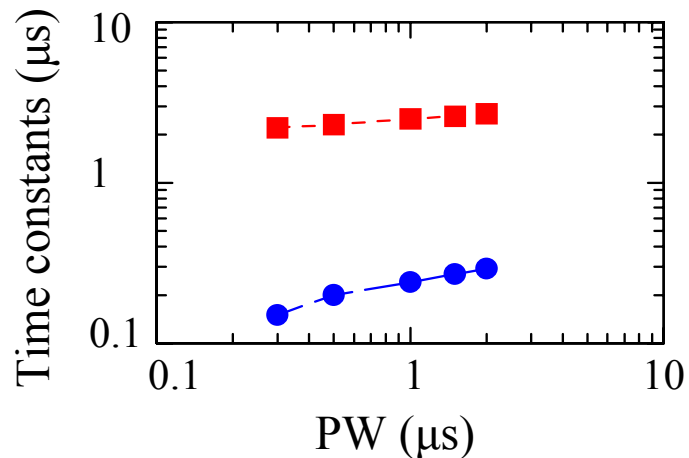
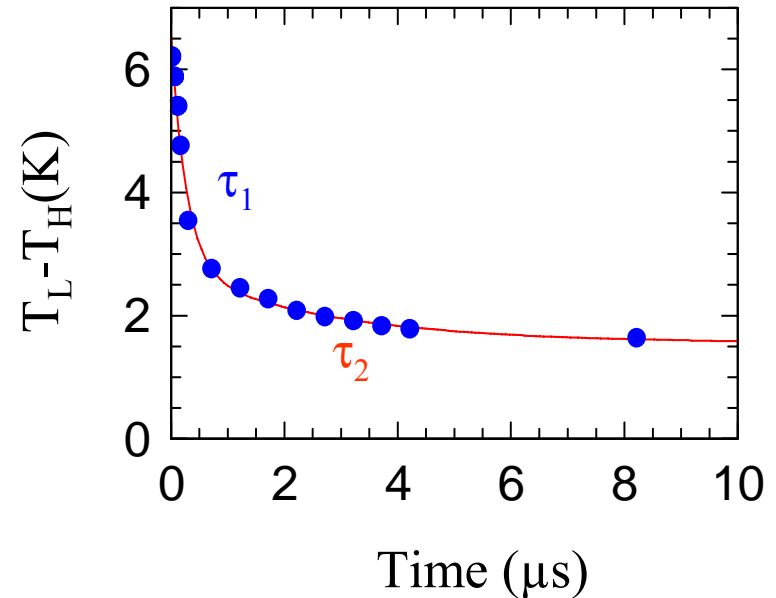


$$\langle T \rangle = T_{\max} \times \text{duty} + T_{\text{off}} \times (1 - \text{duty})$$

$$\langle P \rangle = P \times \text{duty}$$

Post-pulse temperature decay

Duty cycle	PF (kHz)	PW (μs)	τ_1 (μs)	τ_2 (μs)
1.2%	40	0.3	0.15	2.2
2%	40	0.5	0.23	2.3
4%	40	1	0.24	2.5
6%	40	1.5	0.27	2.6
8%	40	2	0.33	2.7

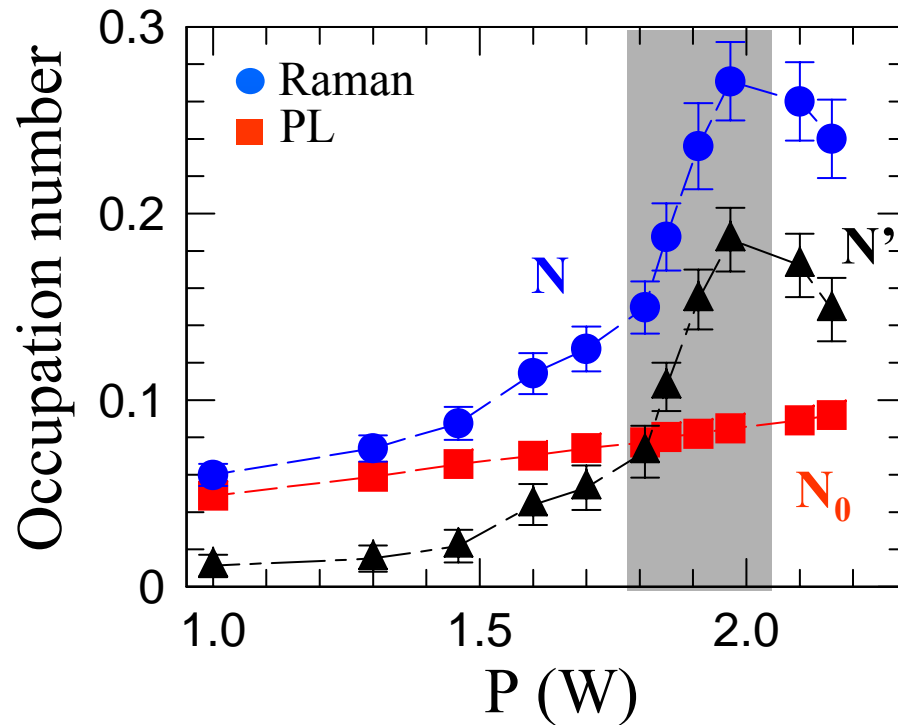


- Bi-exponential decay
[Evans, Indjin, Harrison, Ikonic et al., 2006]
- Short time constant $\tau_1 \rightarrow$ Heat extraction from the active region
- Long time constant $\tau_2 \rightarrow$ Heat extraction from the substrate

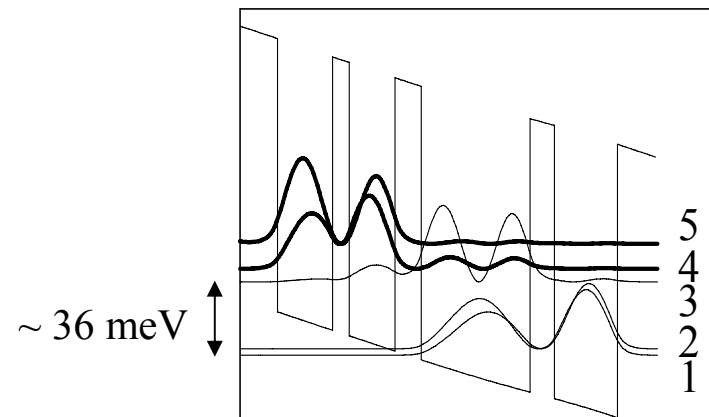
PW increases $\rightarrow \tau_1, \tau_2$ increase due to the temperature dependence of the thermal conductivity

Hot-phonons in resonant-phonon THz QCLs

G. Scamarcio, M. Vitiello, V. Spagnolo, S. Kumar, B. Williams and Q. Hu, *Physica E*, in press (2007)



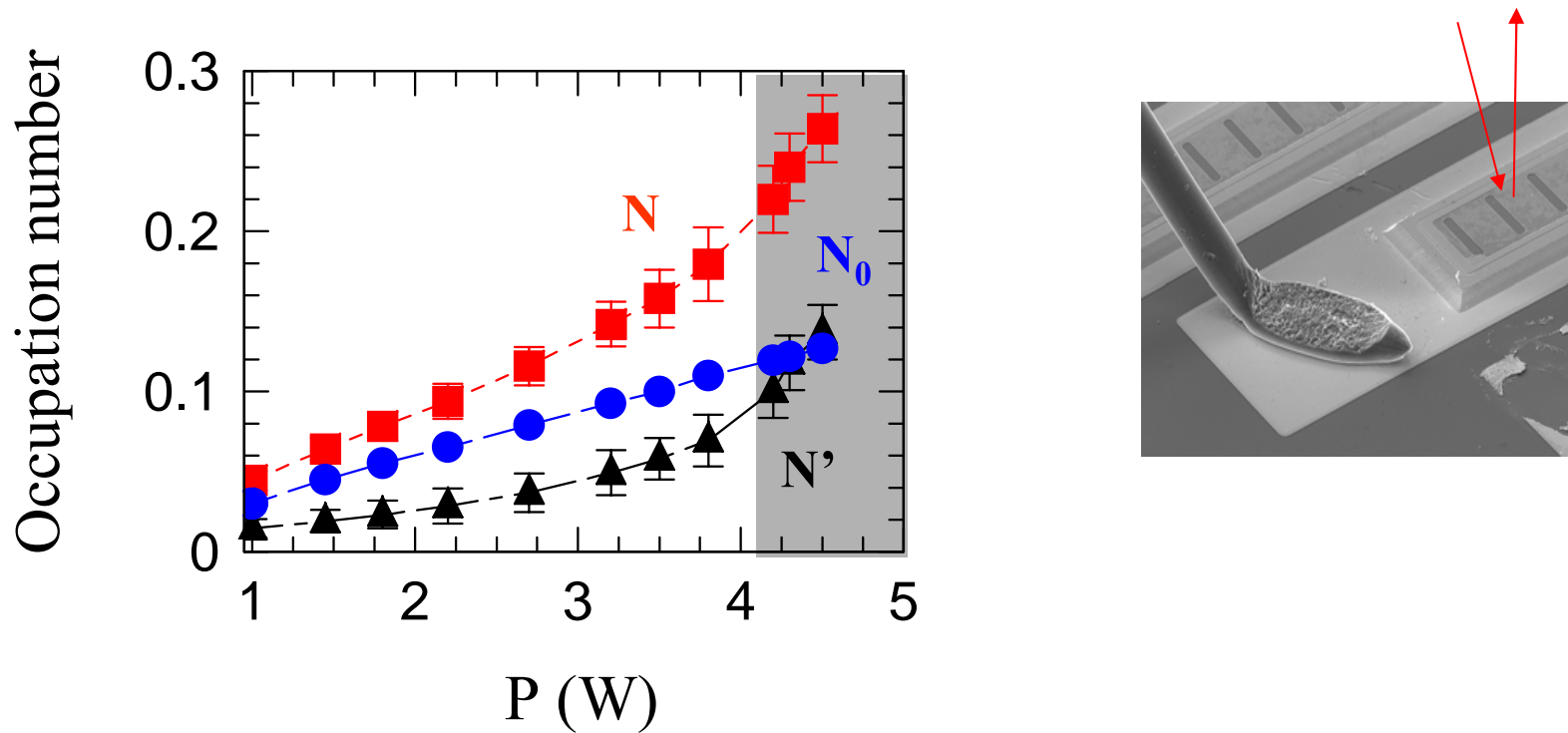
GaAs-IF_{TO} phonons



- THz QCLs allow to study all regimes below and above laser threshold
- Superlinear increase of hot phonon population ($N' = N - N_0$) with power → *stimulated emission of phonons (?)*

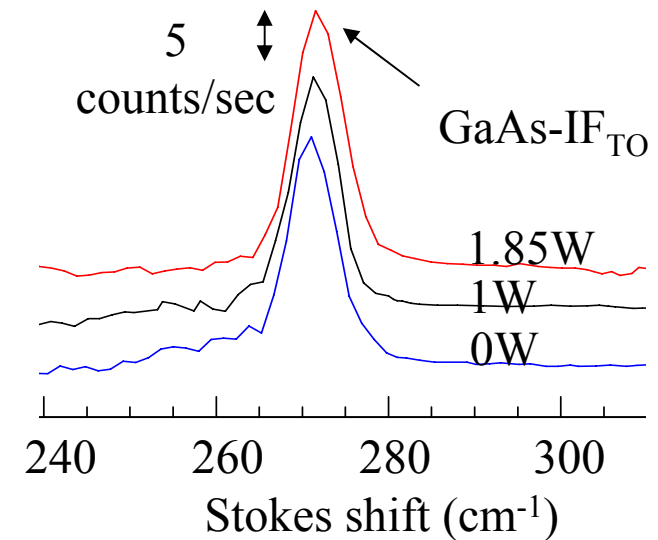
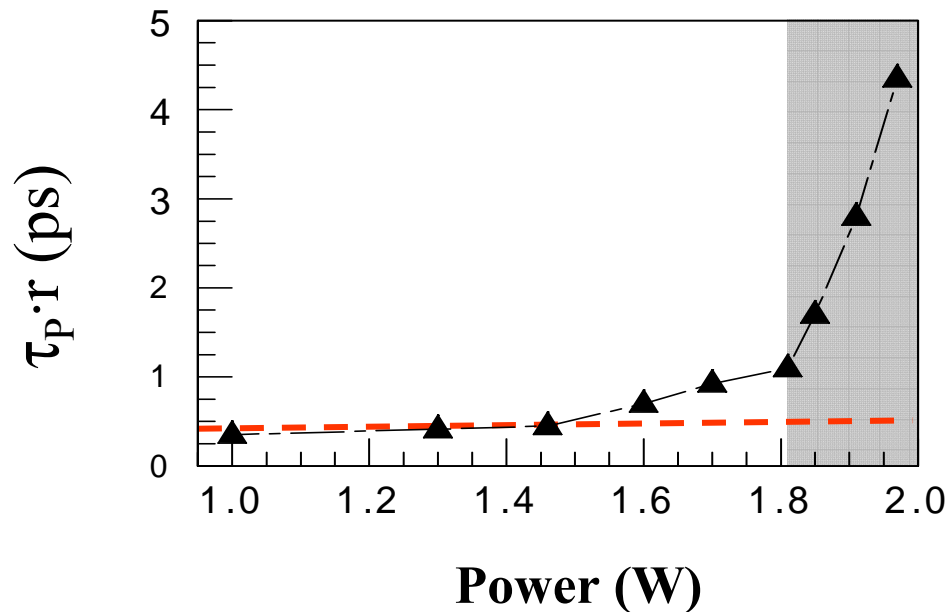
What about LO phonons ?

G. Scamarcio, M. Vitiello, V. Spagnolo, S. Kumar, B. Williams and Q. Hu, Physica E, in press (2007)



- Raman selection rules requires backscattering from the top facet
- Poorer device efficiency and higher laser threshold does not allow to study above lasing regime

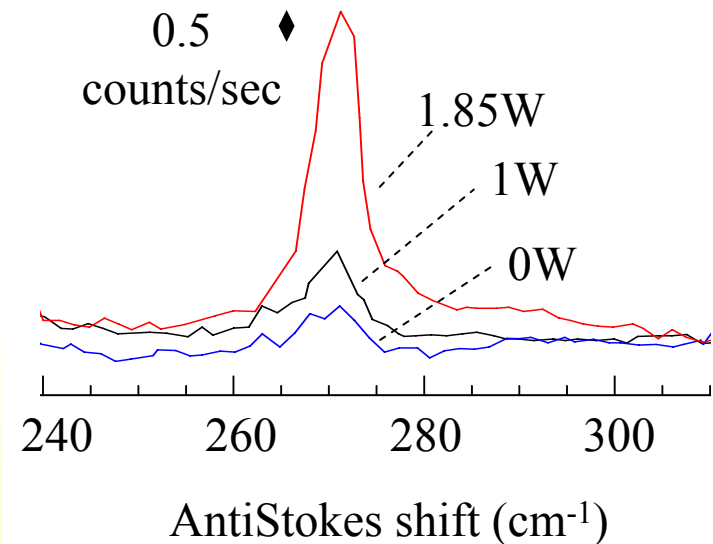
Phonon lifetime and relaxation rate



Rate equation arguments \rightarrow

$$\tau_p \cdot r = \frac{n_{hot}}{P} \cdot \frac{\hbar \omega}{6\pi^2} Ad \cdot [k_{Max}^3 - k_{Min}^3]$$

- $\tau_p \cdot r \sim \text{const}$ if n_{hot} were proportional to P
- Phonon lifetime (τ_p) decreases with $T_L \rightarrow$
in our case phonon relax. rate (r) increases (!)
- Characteristics of *phonon stimulated emission*
- However, *no line narrowing observed* (?!?)



Summary

- ❖ Demonstration of **high power** and **high wall-plug efficiency** ($\eta_w = 5.5\%$) bound-to-continuum 2.83 THz QCLs
- ❖ Development of a new self calibrated experimental approach to measure the total **wall-plug efficiency** of THz QCLs: estimation of the **injection efficiency**
- ❖ μ -probe optical spectroscopy in THz quantum cascade lasers
 - Temperature dependence of the cross-plane thermal conductivity
 - Influence of thermal boundary resistance
 - Time-resolved thermal measurements
 - Non-equilibrium phonon generation

Running:

- Include knowledge on microscopic thermal properties in the design of active regions showing low TBR
- Stimulated emission of phonons